



Process Introduction & Product Specifications

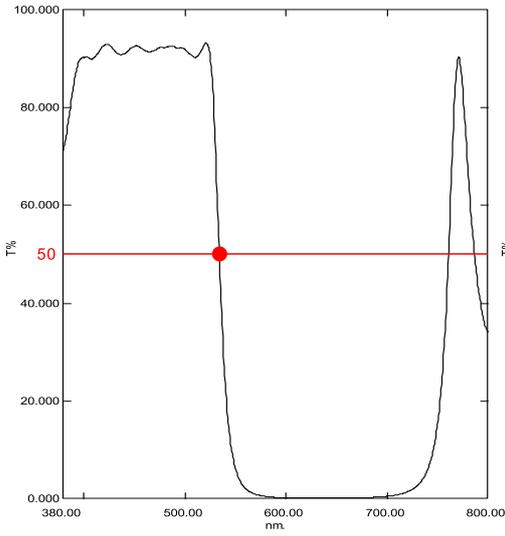
Specification	Photolithography	Laser Engraving
Feature	Leading Technology with Patent. Single layer multi-color GOBO with 1.1mm thickness. Sharpness and bright color.	High precision Laser Engraving. Flexible production for small diameter and batch.
Production Process	Ion Assisted Deposition	
Material	Borosilicate Glass	
Size&Diameter	Ø22.5mm、Ø27.5mm、Ø37.5mm	
Thickness	Mono/multicolor 1.1±0.1mm	Mono 1.1±0.1mm / multi color 4.4±0.4mm
Heat Resistance	300°C, 4~6H	
Specification	Photolithography	Laser Engraving
Line Width (mm)	0.05	0.07~0.1
Line Distance (mm)	0.14	0.15~0.2
Minimum Diameter of circle (mm)	0.05	0.2~0.25
Distance of the center of circle (mm)	0.14	0.15~0.2
Mini font size (Pt)	1	3
Remark	File/picture resolution: 300X300dpi above.	Requirement may differ from material.



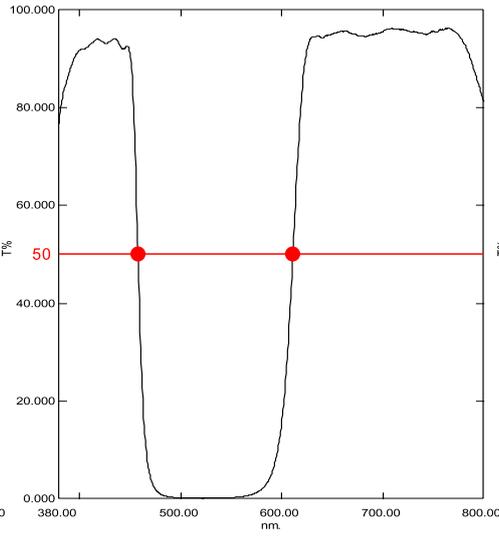
Color Gauge Spectrum

C M Y Spectrum

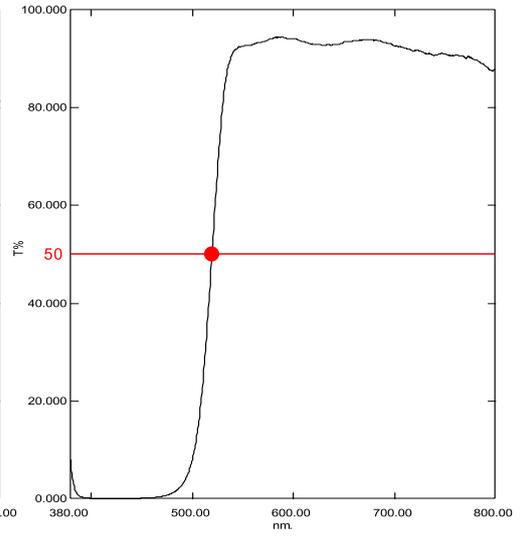
CYAN T50%=535 ±5



MAGENTA T50%=455/610 ±5

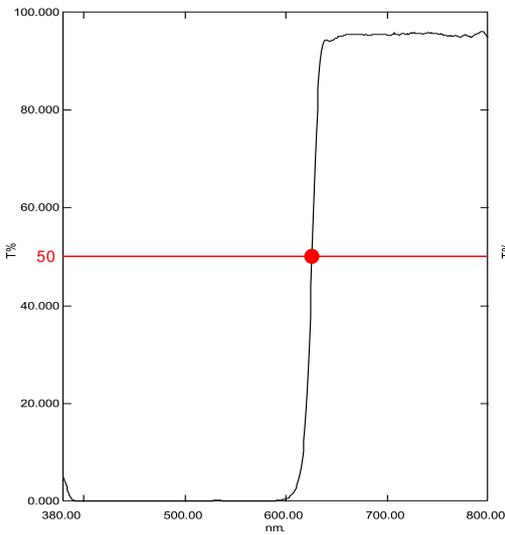


YELLOW T50%=523 ±5

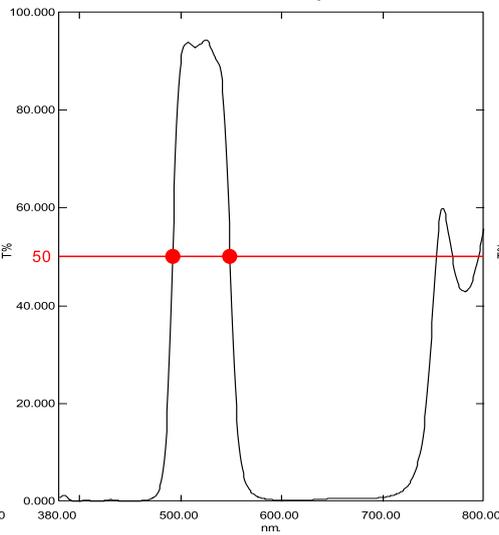


R G B Spectrum

RED T50%=625 ±5



GREEN T50%=493/550 ±5



BLUE T50%=500 ±5

